03-12-25; 1:35PM;T S INTERNATIONAL CARPORATION US OBLON, SPIVAK, MA:0332561398 2003年12月24日: 日本日本 : 1951日 S INTERNATION AA HEET : 19392=6No.

P. 16 15/ 16

: 039256No. 2436

JDOCKET NO.: 219467US0X

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF: SHIGEKI KOBAYASHI, ET AL.

GROUP ARTUNIT: 1713

SERIAL NO.: 10/072,995

EXAMINER: HENRY S. HU

FILED: FEBRUARY 12, 2002

for: process for producing a tetrafluoroethylene polymer EXCELLENT IN STRENGTH

DECLARATION UNDER 37 C.F.R. \$1.192

Assistant commissioner for patents WASHINGTON, D.C. 20231

SIR-

	Now comes Hiroyaki Hiraî wi	to deposes and states	42
	1. I am a graduate of graduate	school	and received my
	master's degree	in the year 1992	2_
	2. Thave been employed by Ashahi	Glass Co., LTE	for // amount As a
ar	an engineer in the s	icld of polyne	rization.

- 3. The experiments in the specification were carried out by me or under my direct supervision and control.
- 4. The stress relaxation time in Example 5 was erroneously reported in the Japanese priority documents as well as in the present application. In Table 1 on page 22 of the specification, the suces relexation time of Exemple 5 should be "703" instead of "520".
- 5. The undersigned petitioner declares further that all statements made herein of his own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false

03-12-25; 1:35PM;T S INTERNATIONAL CORPORATION US OBLON, SPIVAK, MA:0332561398 # A- 3
2003年12月24日:13時19分 S INTAGC 知附定記 CORPORATION AA 8曜子 :083256No. 2436 P. 17:6/ 16

statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of this application or any patent issuing thereon.

6. Further deponent saith not.

Idiroyuki Idirai

Das. 24, 2003

Date

NFO:KAG: